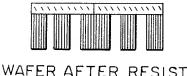
F16.1

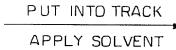


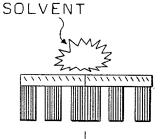
FIG. 2A

F1G.2B



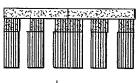
WAFER AFTER RESIST RECESS AND ETCHING





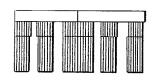
SPINNING

FIG.2C



SPINNING

FIG.2D



PUT INTO BALANCE AND WEIGHT OBTAIN WEIGHT W2

PUT INTO BALANCE AND WEIGHT OBTAIN WEIGHT WI

BAKE, REMOVE SOLVENT

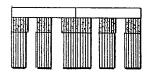


FIG.2E